



## DISCHARGE CHARACTERISTICS OF GLIDING ARC PLASMA REACTOR WITH ARGON/NITROGEN

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### ABSTRACT

Gliding arc discharge plasma has properties of both thermal and non-thermal plasma conditions. Gliding arc discharge plasma in the atmospheric pressure with argon/nitrogen and its characteristics are described. Some experimental results about alternating current gliding arc plasma generator have been obtained. It seems that the current density strongly depends on the gas, and increased with increasing discharge current and gas flow rate. Also, the discharge current of gliding arc discharge plasma in nitrogen gas is greater than one in argon gas because of nitrogen gas need to higher breakdown voltage than argon gas. The intensity of gliding arc discharge plasma increased with increasing the gas flow rate. In addition to the oscillograms of discharge current in each case of argon and nitrogen were obtained. Electron temperatures of argon and nitrogen plasma were calculated to be 22800° K, 8400° K respectively. The characteristics of both argon and nitrogen gases in atmospheric pressure were investigated like current density, electron density with flow rates (5, 10, 20, and 40) Standard Cubic Foot per Hour (SCFH). All the experimental results were tabulated.

### Indexing terms/Keywords

Gliding arc discharge (GAD) plasma; discharge at the atmospheric pressure; Ar and N<sub>2</sub> gases; gas flow rate; diagnostic technique

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## INTRODUCTION

The Gliding arc discharge device is a simple and inexpensive way to generate non-thermal plasma. It has a dual character of thermal and non-thermal plasma, and can involve relatively high electric power compared with the corona discharge. They are highly reactive and often have a high selectivity for chemical processes [1].

The Gliding arc discharge is usually generated between two diverging electrodes typical in a gas flow [1]. The discharge ignites at the shortest distance between the electrodes (1 mm). Typical breakdown voltages are (2-6) kV [2]. The formation of hot quasi-thermal plasma corresponds with a decrease in voltage and strong increase in current [2]. Owing to the gas flow, the discharge moves downward and the length of the plasma column increases. This increasing length causes an increase of the heat losses in the column, which exceeds the input energy of the power supply [2]. The quasi-thermal plasma converts into non-thermal plasma corresponds the decrease in current and the increase in voltage due to the increasing resistivity of the plasma. Eventually, the plasma extinguishes as the power supply cannot maintain such a long plasma column. At this point the recombination of the plasma starts and a re-ignition of the discharge occur at the minimum distance between the electrodes [2]. This causes the self-pulsing nature of the gliding arc discharges, which is always clearly visible in current–voltage waveforms and typically occurs on 10 ms timescales [2, 3].

Gliding arc Discharge (GAD) is a new technology of non-thermal plasma. In recent years, a number of researchers are interested in this new technology for environmental protection.

GAD has been studied for combustion, gas cleaning, and production of syngas [4], and water treatment [5, 6]. GAD can also be magnetically stabilized [7].

GAD plasma efficiently destructed volatile organic compounds (VOCs) (higher than 90%), NO<sub>x</sub>, Sox [8]. The phenol in solution can be degraded by gas-liquid gliding arc discharge [2-9]. This kind of source of high energy electrons without heating the plasma gas in the whole volume of plasmareactor chamber is essential for typical plasma chemistry applications.

In this paper, the source of GAD experiment was AC power supply (6.6 kV) with frequency 50 Hz. The gases which used in the experiment were Argon (Ar) and Nitrogen (N<sub>2</sub>). The discharge characteristics of each gas like its discharge voltage, discharge current, current density, electron temperature and electron density were investigated.

The characteristics of discharge current with different gas flow rate of Ar and N<sub>2</sub> were studied and illustrated in graph.

The equations of the ionization process in Ar and N<sub>2</sub> were clarified.

The photographs of each gas were illustrated at different flow rates (5, 10, 20, 40) SCFH to follow the GAD plasma streamer.

The mathematical equations for calculating current density, electron temperature and electron density were obtained. Some curves were drawing like electron density varies with flow rate of gas.

## Experimental Setup

GAD experiment consists of two identical diverging electrodes made of copper each with length (44mm), width (26mm), thickness (15mm), arc (deviation of electrode) angle (120°) and the gap between two electrodes (1 mm).

The electrodes are connected to AC power supply (6.6kV) via resistor (R=200kΩ) to avoid high current. The input voltage was controlled by using variac (slidacs).

The AC power supply is step-up transformer with ratio (1:30). The gas was injected from narrow tube located from narrow gap between two electrodes.

The two electrodes and the gas pipe were located inside glass bottle, see Fig. 1.

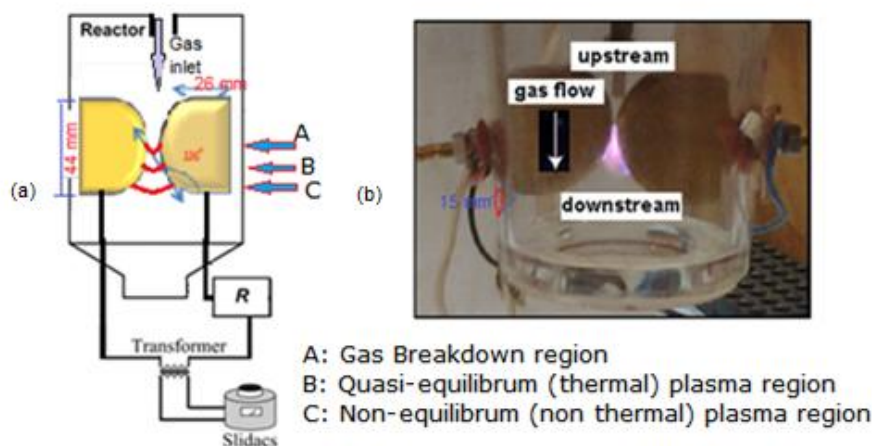


Fig. 1(a) Schematic of gliding arc and the electric scheme, (b) GAD plasma photo



Figure1 represented the schematic diagram of experimental setup with indication of plasma stages.

In A, as shown in fig1, was the region of Gas Breakdown.

In B, was the region of quasi-equilibrium (thermal) plasma.

In C, was the region of non-equilibrium (non-thermal) plasma.

The gases used for the experiment were Ar and N<sub>2</sub> where gas flow rate was controlled from 5 SCFH to 50 SCFH by the pressure regulator. Discharge voltage was controlled by the voltage slide regulator and increased by using the high voltage transformer (1:30), and then high voltage was applied to the electrodes. Therefore, the frequency of electric discharge is 50 Hz. Discharge current was measured using both of clamp digital meter (for digital value) and rogowski coil to connect to oscilloscope (for following the current oscilligram).

## Methods of Analysis

### 1. Electric field(E)

$$E = V/d \quad (1)$$

(Reduced electric field = breakdown voltage /gap distance)

So, E is estimated to be (2.7 kV/mm) for Ar gas and (3.3 kV/mm) for N<sub>2</sub> gas at gap distance =1mm where V<sub>br</sub> (Ar) =2.7 kV, V<sub>br</sub> (N<sub>2</sub>) = 3.3kV.

### 2. Dissociation and Ionization

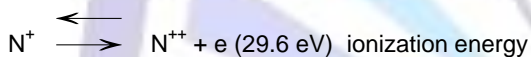
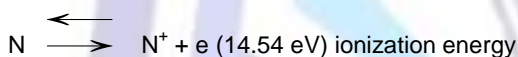
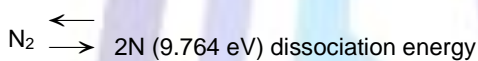
The molecules constitute of elements under ionic, covalent, metallic and van der Waals bonds for inert gases. These bonds may be single, double or tripple one. Dissociation is a process required to rupture the combining bonds between atoms forming the molecules.

Dissociation energy required increases from single to double to tripple bond, with a weak value for van der Waals type for inert gases.

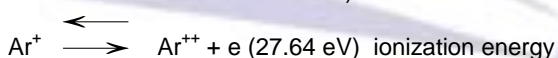
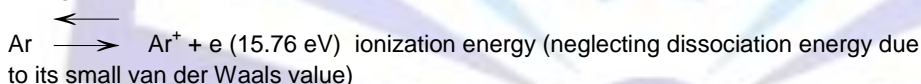
In the present paper, N<sub>2</sub> gas molecule has a tripple bond type and needs of 9.8 eV for dissociation [12]. But Ar gas needs small dissociation energy compared to N<sub>2</sub> because its bonds are the weak van der Waals type [13].

For ionization energy required for N<sub>2</sub> and Ar are nearest from each other with values of 14.54 and 15.76 eV for the two gases respectively [13]. The above results are shown in table 1.

In nitrogen, [14],



In Argon, [15],



where: (1eV = 11600 K)

### 3. Electron temperature(T<sub>e</sub>)

Nitrogen at 8000 K has an enthalpy five times higher than argon [14], since the energy gained by the one-atom gases in the plasma column is given by the specific heat and ionization energy, while in two-atom gases, in addition, the great volume of energy is obtained from the dissociation of molecules into atoms.

Electron temperature can be roughly calculated using Einstein's equation of electrons in argon and nitrogen [16].

Using the following equations

$$k_B T_e / e = D_e / \mu_e \quad (a)$$

$$N = 3.3 \times 10^{16} P \quad (b) \quad (2)$$

$$D_e = K \cdot 10^5 / P \quad (c)$$

where k<sub>B</sub>, e, μ<sub>e</sub>, and D<sub>e</sub> are Boltzmann constant, electron charge, electron mobility, electron diffusion constant (expressed as a function of E/N) respectively.



Also N, P is Neutral gas density and atmospheric pressure respectively ( $E/N = 1.1 \times 10^{-15} \text{ V.cm}^2$  for (Ar),  $E/N = 1.3 \times 10^{-15} \text{ V.cm}^2$  for ( $N_2$ )). Also k is the electron diffusion constant (2.9for ( $N_2$ ) and 6.3for (Ar)).

From the previous data

$D_e = 828 \text{ cm}^2/\text{s}$  (for Ar),  $D_e = 381 \text{ cm}^2/\text{s}$  (for  $N_2$ )

and  $\mu_e = 434 \text{ cm}^2/\text{V.S}$  and  $D_e/\mu_e = 1.9 \text{ eV}$  for (Ar)

Also,  $\mu_e$  (for  $N_2$ )  $= 552 \text{ cm}^2/\text{V.S}$ ,  $D_e/\mu_e = 0.7 \text{ eV}$  for ( $N_2$ )

So,

$T_e = e/K_B \cdot D_e/\mu_e = 22800 \text{ K} = 1.9 \text{ eV}$  for (Ar),

$T_e = e/ K_B \cdot D_e/\mu_e = 8400 \text{ K} = 0.7 \text{ eV}$  for ( $N_2$ ).

Which means that 1 eV equivalent to  $= 11600 \text{ K}$

#### 4. Current density(J)

The current density (J) was obtained from dividing the discharge current (I) by the area of plasma (S).

$$J = I / S \quad (3)$$

The cross section area which the current crosses is a rectangle shape of length equal to the thickness of electrodes 15 mm with side drop starting from the minimum distance of electrodes downward which differs from the used gas to another.

In the present experiment, the side length equal 10 mm and 12 mm and area of  $1.5 \text{ cm}^2$  and  $1.8 \text{ cm}^2$  for (Ar) and ( $N_2$ ) respectively.

The previous results are collected and given in table 2.

**Table 1 molecules bond type and related dissociation and ionization energies**

Gas	Bond type	Dissociation energy(eV)	Ionization energy(eV)
$N_2$	Triple	9.8	14.54
Ar	Van der waals	Weak values	15.76

**Table 2 constants relating Einstein's equation and other gas constants**

( $k_B = 1.38 \times 10^{-23} \text{ J/k}$ ,  $e = 1.6 \times 10^{-19} \text{ C}$ ,  $P = 760 \text{ torr}$ )

Gas	E/N $\text{v.cm}^2$	$D_e$ $\text{cm}^2/\text{s}$	$\mu_e$ $\text{cm}^2/\text{v.s}$	$D_e/\mu_e$ $\text{eV}$	$T_e$ $\text{k}^\circ$
$N_2$	$1.3 \times 10^{-15}$	381	552	0.7	8400
Ar	$1.1 \times 10^{-15}$	828	434	1.9	22800

At flow rate 5 SCFH,  $J = 20 \text{ A/cm}^2$ ,  $J = 27.8 \text{ A/cm}^2$  for (Ar) and ( $N_2$ ) respectively, with  $S = 1.5 \text{ cm}^2$ ,  $S = 1.8 \text{ cm}^2$  for (Ar) and ( $N_2$ ) respectively.

#### 5. Electron density( $n_e$ )

The averaged electron density( $n_e$ ) can be calculated from the following equation, [11],

$$n_e = J / (e E \mu_e) \quad (4)$$

The above equation can be rewritten as follows

$$n_e = J / (\mu_e p \times (E/P) \times e) \quad (5)$$

Accordingly  $n_e$  at 10 SCFH equal to  $4.4 \times 10^{13} \text{ cm}^{-3}$ ,  $2.6 \times 10^{13} \text{ cm}^{-3}$  for (Ar) and ( $N_2$ ) respectively.

The nitrogen has an electronegative characteristics gas, therefore the electron density number becomes smaller and decreasing electron density leads to increasing resistivity, see table 3 for a comparison between (Ar) and ( $N_2$ ) gases.

## Results and discussions

The current flowing through the gas was measured by using clamp meter and Rogowski coil. The discharge current increased with increasing gas flow rate as shown in fig. 2. This may be due to promotion of gas ionization by the gas flow rate increasing. In this experiment, high electric power was supplied to the 1 mm gap electrode. In Argon gas the ionization is promoted with increasing the gas flow rate, the electron density increase and then discharge current will increase. Nitrogen gas has high internal energy over argon due to the dissociation reaction in the  $N_2$  prior to ionization [10] and the dissociation energy for (Ar) is very small because of its van der waals bond type compared to that for  $N_2$  of tripple bond type [12, 13].so; Nitrogen gas need to higher breakdown voltage than Argon gas where,  $V_{br}(N_2) = 3.3kV$ ,  $V_{br}(Ar) = 2.7kV$ . See Fig. 2, where the discharge current in  $N_2$  gas is greater than the discharge current in Argon gas and as the gas flow rate increase from (5-40) SCFH, the discharge current increase.

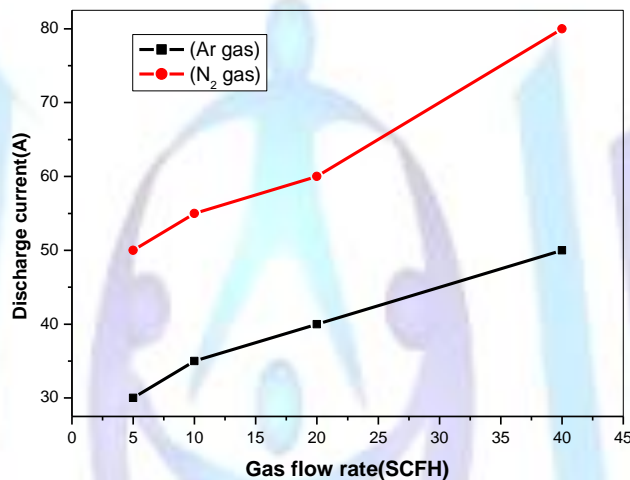


Fig. 2: Discharge current for Ar and  $N_2$  gases and flow rates.

It had seen from the experiment that the process of plasma formation of a two-atom (diatomic) gas differs from the process of plasma formation of a one-atom (mono-atomic) gas. The difference consists in the fact that the ionization of two-atom gas atoms starts after dissociation of its molecules. Nitrogen dissociates at a temperature of about 8500 K [11].an energy of 9.8 eV [12] which is required for rupturing the triple bond molecule of nitrogen while argon dissociate at a low eV values because its molecules constitute under the weak van der waals bond [13].

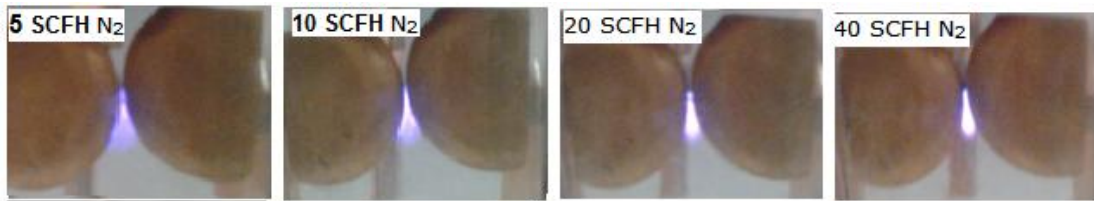
Figure3, shows the photographs of GAD plasma for different Argon gas flow rate at 2.7 kV discharge voltage and take these photographs at fixed distance (10 cm).

With increasing the gas flow rate, emission intensity increased in the upper-stream side. On the other hand, electric discharge area decreased with increasing gas flow rate in the downstream side. These results suggest that the upstream area is a positive column of the main arc discharge which can be controlled by discharge voltage, and downstream domain is GAD plasma which exists between electrodes that depend on the gas flow.



Fig. 3: photograph of GAD plasma for different argon gas flow rate at 2.7 kV discharge voltage.

Also, Figure4, shows the photograph of GAD plasma for different Nitrogen gas flow rate at 3.3 kV discharge voltage, take these photographs at fixed distance (10 cm).



**Fig. 4: photograph of GAD plasma for different Nitrogen gas flow rates at 3.3 kV discharge voltage.**

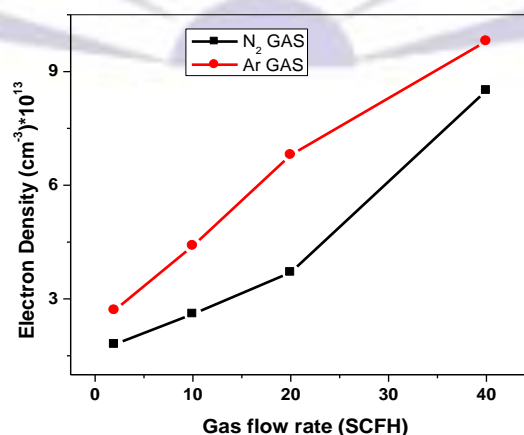
It was observed from the previous photographs that in each case of Ar, N<sub>2</sub> the electric discharge area decreases with increasing the gas flow rate while the emission intensity increases with the gas flow rate. Also, it was observed that the emission intensity of N<sub>2</sub> GAD plasma at different flow rates is higher than the other in Ar GAD plasma. Also the plasma diversion or elongation in N<sub>2</sub> is more than in Ar. There are also products of GAD plasma like ozone (O<sub>3</sub>), oxygen (O), hydroxyl group (OH), hydrogen peroxide (H<sub>2</sub>O<sub>2</sub>) and ultraviolet rays (UV). These characteristics are important for applications like ozone generation, sterilization for environmental applications, and biomedical applications like cancer treatment.

All experimental results are tabulated in the shown Table 3.

**Table. 3.Results of the comparison between Ar, N2 gases.**

Comparison Faces	Ar gas				N <sub>2</sub> gas			
	5	10	20	40	5	10	20	40
Flow rate(SCFH)	5	10	20	40	5	10	20	40
Charging voltage(kV)	2.7	2.7	2.7	2.7	3.3	3.3	3.3	3.3
Discharging current(A)	30	35	40	50	50	55	60	80
Power (kW)	81	95	108	135	165	181	198	264
Side drop (mm)	10 mm				12 mm			
Area S (cm <sup>2</sup> )	1.5 cm <sup>2</sup>				1.8 cm <sup>2</sup>			
Current density (A /cm <sup>2</sup> )	20	23.3	26.7	33.3	27.8	30.6	33.3	44.4
Electron density(cm <sup>-3</sup> )*10 <sup>13</sup>	2.7	4.4	6.8	9.8	1.9	2.6	3.7	8.5

Figure 5, shows an electron density of argon and nitrogen plasmas in gliding arc discharge (GAD) plasma at different gases flow rate (SCFH).



**Fig. 5: Electron density as a function of argon and nitrogen gases flow rate**

The discharge current increased with increasing gas flow rate (Ar and N<sub>2</sub>). This may be due to promotion of gas ionization by the gas flow rate increasing. In GAD plasma, high electric power density was applied to the gap electrode. Therefore, ionization is promoted with the increase in a gas flow and electron densities increased, and then discharge current increases.

Figures 6 and 7 indicate that the GAD plasma area depends on the discharge current. As the discharge current increases, the GAD plasma area decreases while the electrical emission intensity increases (as shown in the photographs in Fig. 3, Fig. 4).

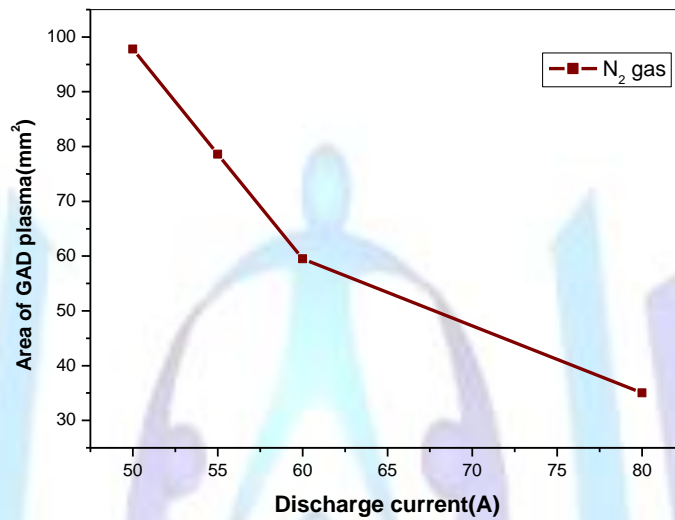


Fig. 6. Dependence of the GAD plasma Area of N<sub>2</sub> gas on discharge current

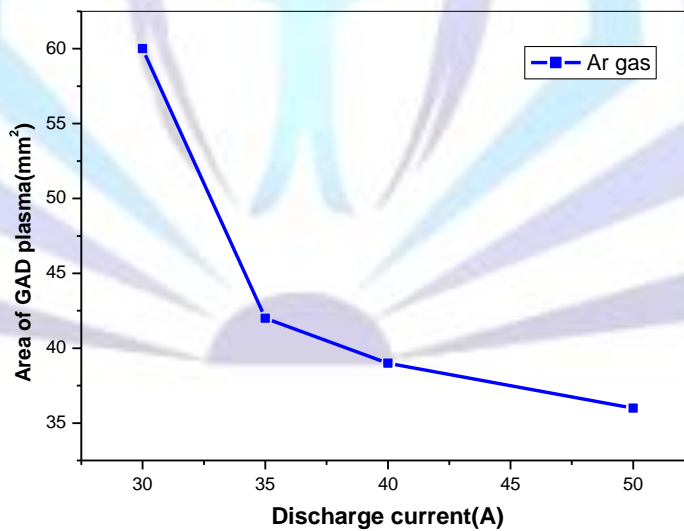


Fig. 7. Dependence of the GAD plasma Area of Ar gas on discharge current



## Conclusion

Gliding Arc Discharge plasma has demonstrated the potential of combining advantages of both thermal and non-thermal plasmas for certain applications in optimized regimes.

The electron density of argon plasma (mono-atomic gas) is greater than nitrogen plasma (diatomic gas) because of the presence of negative ions in nitrogen plasma, the number of electrons is smaller in this case, which required the increase in discharge voltage of nitrogen in comparison with the argon plasma. Because of nitrogen an electronegative gas, the electron density number becomes smaller, decreasing electron density leads to increasing resistivity.

The streamer of GAD plasma was represented using Ar, N<sub>2</sub> gases at different flow rates to show that the intensity of emitted light increases with increasing the flow rate which is important in certain applications.

All the results were tabulated in values obtained from calculation in comparison between Ar, N<sub>2</sub> to obtain the characteristics of each gas.

The device of GAD plasma can be used in future in some vital and important applications: environmental applications like sterilization and gas cleaning, biomedical applications like plasma healing, blood coagulation and cancer treatment.

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